

Impact of the circuit layout on the charge collection in a monolithic pixel sensor Corentin Lemoine

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Symmetric sensor with asymmetric efficiency?

- See Sara's presentation on H2M chip, 65nm monolithic CMOS
- Explain efficiency asymmetry pattern with simulation



Collection electrode

PMOS



H2M layout

- Digital: several long and thin standard cell columns
- Analog: All pmos grouped in a single large nwell*



Sensor structure: H2M cross section

• Local variation of the electric field close to the n-wells of the circuitry compared to simulation without the wells for the circuit



From TCAD simulation to Monte Carlo

- One MIP perpendicularly incident to the sensor
- Single position, in analog n-well
- With n-well: significant slowdown of charge collection
- Similar total collected charge (~10% variation)



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Monte Carlo simulation

- Compare to 300e- threshold
- High statistics over the full pixel

15

10

5

0

-5

-10

-15 -

-10

No asymmetry pattern

Allpix²: test beam simulation

- Perpendicular 5GeV e- beam
- Lifetime: SRH-Auger model •
- Mobility: Masetti-Canali model .
- Timestep: ≤2ps



Collected

Monte Carlo simulation

- Compare to 300e- threshold
- High statistics over the full pixel
- No asymmetry pattern for long simulated integration time



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Collected



Importance of rise time

\star Collection electrode



Allpix²: **Simple iron source**

- Point like deposition of 1.6 or 1.8ke-
- Lifetime: SRH-Auger model
- Mobility: Masetti-Canali model
- Timestep: ≤2ps



Total charge collected is uniform

Rise time (10% to 90%) is strongly asymmetric

Ballistic deficit



- For TOT, return to baseline at constant slope, set by 1/iKrum
- For the same total charge, collection speed affects amplitude through ballistic deficit
- Faster return to baseline (=higher iKrum) is more affected

Simulated output of the CSA for the same input charge (1600e-) but different rise time.

Including the front end in the simulation



Including the front end in the simulation

- Front end response is **not** linear (e.g. return to baseline)
- Linear approximation overestimates the ballistic deficit



Including the front end in the simulation





Simulation results

Allpix²: test beam (see parameters slide 8). Spectre: schematic view, liberal, without noise. Analysis: adding ~33e- rms noise 3um track smearing (telescope resolution) Calibration on 1600e- pulse with ~70ns rise time

Measurements Vbias = - 1.2 V, ikrum = 21, THL = 323 e-Efficiency = 87.2% Efficiency = 88.4% 1.00 1.00 70 60 60 -0.95 0.95 \star \star * * 50 50 in-pixel y_{track} [µm] in-pixel y_{track} [µm] 0.90 -0.90 Efficiency Efficiency 0.85 0.80 0.80 20 -20 \star * \star 0.75 0.75 10 -10 0.70 0 -0.70 30 60 40 50 10 20 20 30 40 60 70 0 10 50 in-pixel x_{track} [µm] in-pixel x_{track} [µm]

> Collection electrode \star

Simulations

For the simulation, the plotted data are

the same for all 4 pixel

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Simulation results

• Asymmetry and trend reproduced Still not perfect matching with data



Conclusions

- The asymmetric efficiency pattern of the H2M was reproduced in a simulation combining TCAD, Monte Carlo and circuit simulator.
- The underlying mechanism is that specific circuit layout features can slow down the charge collection for large pixel pitches.
- The fast H2M front end filters out slower signals, therefore impacting the efficiency at high threshold.
- No such effects observed other prototypes in the same technology (APTS, DPTS, MOSS...)
- Now this unexpected effect can be evaluated at the design stage, which is crucial for future large pitch and fast front end sensors. Exercised on the future MOSAIX sensor, no expected issue.